

CO₂ reduction with H₂O over Ga₂O₃ photocatalysts prepared at various calcination temperatures

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Gallium oxide (Ga₂O₃) photocatalysts can reduce CO₂ with H₂O to produce CO, although the reaction rate of CO production is very low. It has been reported that the loading of Ag on Ga₂O₃ promoted CO production [1], on the other hand, improvement of Ga₂O₃ structure should be also essential. In our previous work [2], Ga₂O₃ loaded Al₂O₃ samples (Ga₂O₃/Al₂O₃) were prepared to change coordination structures around Ga atoms, and we succeeded to enhance CO production rate. Recently, we found that the photocatalytic activity of Ga₂O₃ depended on the calcination temperature for a Ga₂O₃ precursor in the preparation stage. Therefore, in this study, we will discuss the reason why the CO production was enhanced by controlling calcination temperature.

Ga₂O₃ samples were prepared by calcination of Ga(NO₃)₃·8H₂O powder in the air at given temperatures (673 - 1173 K) for 4 h. We carried out photocatalytic CO₂ reduction with H₂O over the Ga₂O₃ samples. Fig.1 shows CO production rate for each Ga₂O₃ sample. Ga₂O₃ prepared by calcination at 823 K (Ga₂O₃(823 K)) showed a specifically high activity for CO production, although the H₂ production rate for this sample was comparable with those for Ga₂O₃ (673, 773, 873 K). It was found that the H₂ production rate increases with the surface area of the sample.

In XRD measurement of Ga₂O₃(823 K), very weak and broad diffraction peaks were observed, suggesting the formation of low crystallinity β-Ga₂O₃. Taking into account that a low crystallinity photocatalyst has many defects to promote the recombination of excited electron-hole pairs, high CO production activity for Ga₂O₃(823 K) would be resulted from an improvement of CO₂ adsorption process rather than electrons and holes diffusion process. Therefore We performed FT-IR measurements for chemisorbed species on Ga₂O₃ samples after introduction of CO₂. It was revealed that adsorbed species on Ga₂O₃(823 K) are different from those on other Ga₂O₃ samples. The FT-IR spectrum of Ga₂O₃(823 K) indicated preferential formation of CO₂ species interacting with water adsorbed on Ga₂O₃ surface.

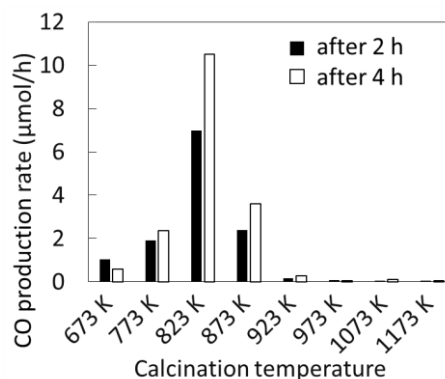


Fig. 1 CO production rates for Ga₂O₃ samples prepared by calcination at different temperatures.

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[1] Yoshida H, Zhang L, Sato M, Morikawa T, Kajino T *et al.* Catal. Today **251**, 132(2015).

[2] M. Akatsuka, T. Yoshida *et al.* Catal. J. Phys. Conf. Ser., conference 1, **712**, 012056 (2016).